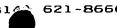
Group Art Unit:

Examiner:

Docket No.:



PATENT APPLICATION

1752

Y. Clarke

105875

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Masaru MITSUI et al.

Application No.: 09/509,472

Filed: April 21, 2000

PHOTOMASK BLANK, PHOTOMASK, METHODS OF MANUFACTURING THE

SAME AND METHOD OF FORMING MICROPATTERN

SUPPLEMENTAL AMENDMENT

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

Sir:

For:

Supplemental to the amendment filed on January 22, 2002, please further amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claims 6, 10 and 13 as follows:

The photomask blank according to Claim 4, wherein the (Thrice Amended) 6. carbon content is 0 to 25 atomic% and the oxygen content is 0 to 70 atomic%.

The photomask blank according to Claim 9, wherein the (Thrice Amended) 10. thin film has an oxygen content that continuously decreases and a carbon content that continuously increases from the thin film surface side to the transparent substrate side, nitrogen is contained in the nitride film in a clatively greater amount than the amount of nitrogen contained in the thin film, and the amount of the metal decreases as the amount of nitrogen in the nitride film increas sl



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FACSIMILE TRANSMISSION COVER SHEET

March 4, 2002

| To: | Examiner Yvette Clarke U.S. PATENT AND TRADEMARK OFFIC Group Art Unit 1752 | APPLICATION NO. 09/509,472 |
|----------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------------|----------------------------------------------------------------------------|----------------------------|
| | 1-703-872-9493 | |
| From: | David M. Lafkas | |
| Your | Ref.: Application No. 09/509,472 | Our Ref.: 105875 |
| Numb | er of Pages Sent (Including cover sheet): | 4 |
| Prepai | red By: DML | |
| Comments: | | |
| Examiner Clarke: | | |
| Further to our March 4, 2002 telephone conversation, attached is a Supplemental Amendment for the above-identified application. If you have any questions or comments regarding the Supplemental Amendment, please do not hesitate to contact me at your convenience at 314-621-8383. | | |
| | a. J. H. H. | |
| Davi | d M. Lafkas | |
| Registration No. 50,424 | | |

Sent by: __rxg____ D __ M __
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